### Introduction to MPD used for MEMS & Sensors

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#### MESOLINE

### — Agenda

- About us
- Intro to Microchannel Particle Deposition (MPD)
- Comparison to other microfab methods
- Next generation products
- Applications
- From Micro-molding to MPD
- Mesoline's printing service
- Summary



#### — About us

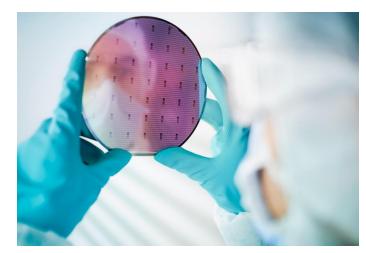
Mesoline has developed a 6 & 8-inch substrate size compatible new microfabrication technology: **microchannel particle deposition (MPD).** 

MPD offers ultra-small and reproducible micro features fabricated with extensive parallelization and high scalability. Mesoline offers MPD through manufacturing services.

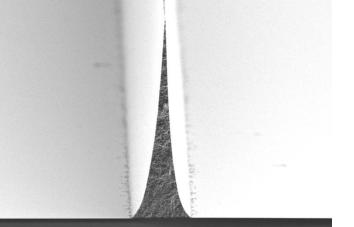
Founded out of Caltech in 2017, and Mesoline is acquired by Aalberts N.V. (stock listed) in 2021. We are headquartered in The Netherlands.



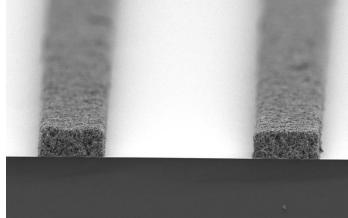
### — The Strength of MPD



Scalability Deposition at wafer-scale in just 15 minutes

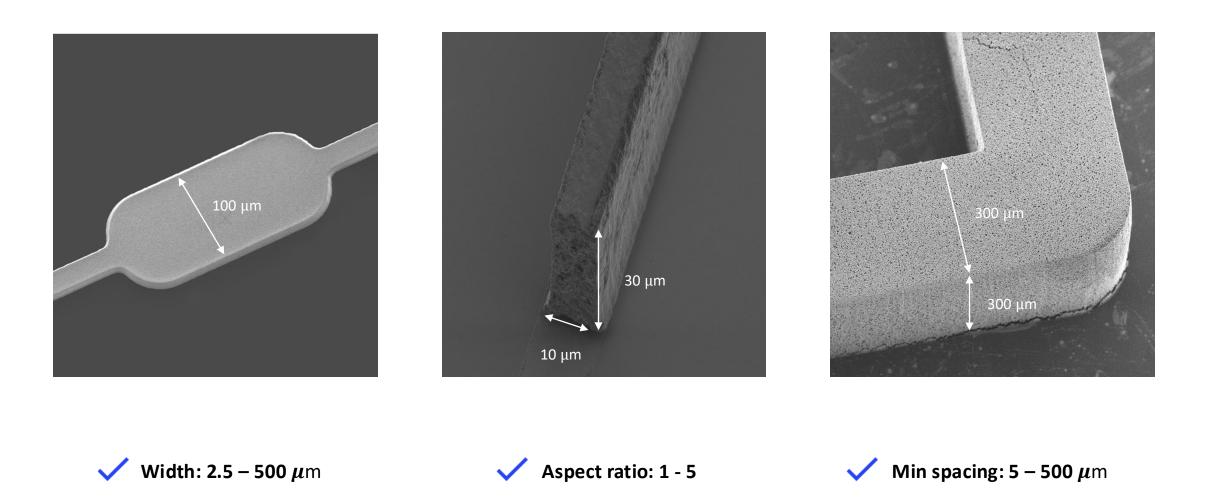


<u>Accuracy</u> Full 3D-contolled microstructures



Reproducibility Continuously stamping the same

#### What MPD Creates?



### Detailed process flow

In-house technology Wafer (MEMs) Substrate is provided by 3<sup>rd</sup> party Stamp In-house developed Sintering and fabricated MESOLINE Ink Provided by 3<sup>rd</sup> party or in-house **MPD** machine developed



Sellable product

#### Technology readiness

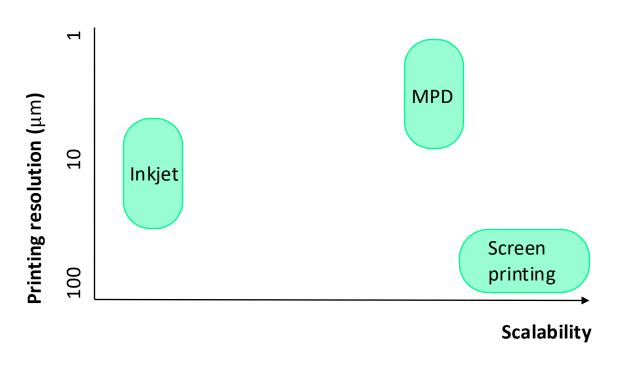
- **Extensive parallelization:** 40.000 features possible
- Yield: 95%+ on pre-production test-targets
- Wafer-level process: 6 and 8-inch
- Alignment accuracy: ±10 um over entire wafer
- Feature thickness variation: ≤ 5%
- Multiple materials: up to 4 in one process step

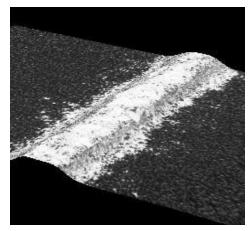


MPD printed 6-inch wafer with 95%+ yield

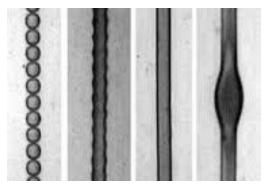
### Additive manufacturing landscape

MPD offers ultra-small & reproducible features made from multiple materials while ensuring extensive parallelization and high scalability



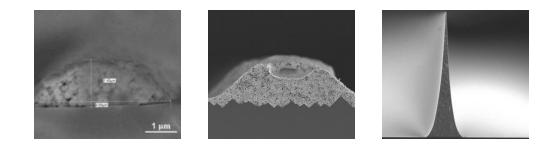


Example of **screen printing** which is inherently limited in size and precision



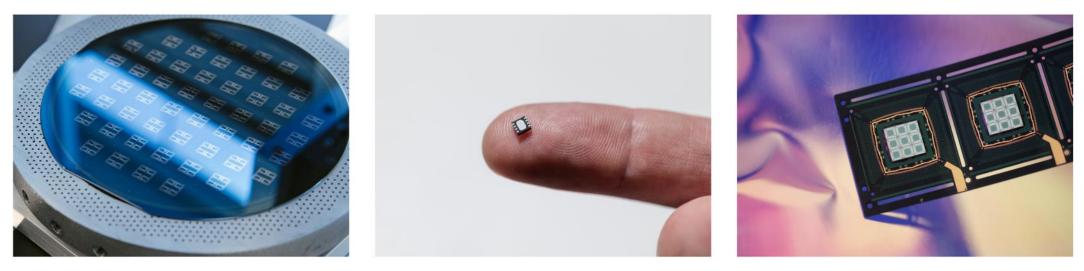
Example of **inkjet** which is inherently limited by scalability and drop-size variability

#### — Comparison



Fabrication Technology	Inkjet	Screen-printing	MPD
Feature size range (µm)	30 - 500	30 – 500	2.5 - 500
Min. line spacing (µm)	~20	~50	~2.5
Aspect ratio (h/w)	1	0.4	5
Scalability	Poor	High	Medium to high
Multi-material printing	Yes	No	Yes

#### Next Generation Products



MEMS

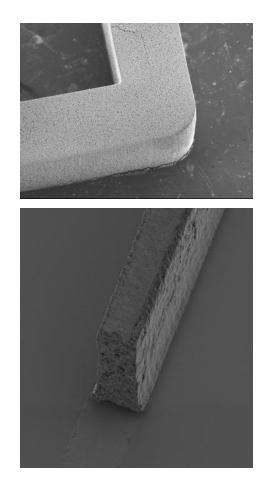
Sensors

Packaging

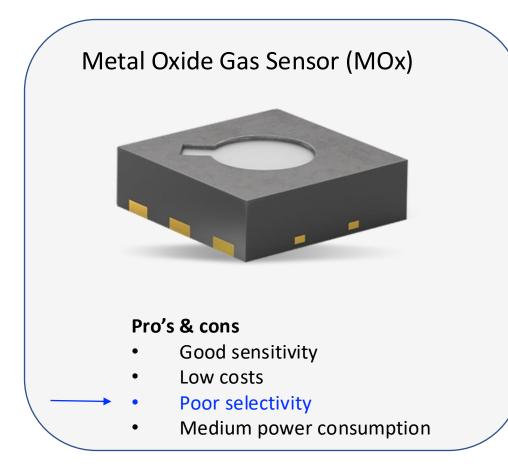
We help our customers fabricate new MEMs and sensor products ranging from improved packaging solutions through deposition of functional elements

### Deposition of nanomaterials

Printable Materials	Applications
Tin-oxide (SnO <sub>2</sub> ), Zink oxide (ZnO) and Tungsten oxide (WO <sub>3</sub> )	Sensing element MOX sensor
Glass frit	Bonding/packaing
Palladium oxide (PdO), Copper oxide $(Cu_2O_3)$ and Molecular Sieves	Hydrogen & moisture getter
Ferrite (Fe <sub>3</sub> O <sub>4</sub> )	Magnetic field sensor and zero power wakeup for IoT
Gold (Au), Platinum (Pt), Silver (Ag)	(Bio-compatible) conductor for biosensing or electrochemical sensor

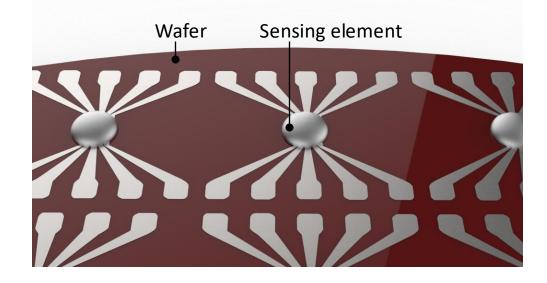


#### Metal oxide gas sensor



#### Working principle

The sensing element changes resistance if a certain (target) gas is present in the atmosphere around it. By measuring the resistance or impedance change one can determine how much of a gas is present



#### — Gas sensor use-cases



- Diaper state detection
- Food freshness detection
- Wildlife fire detection
- Methane detection

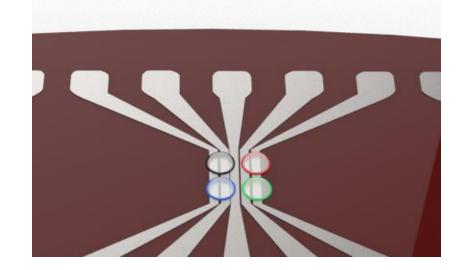
### — Selectivity

# Drop-casted sensing element

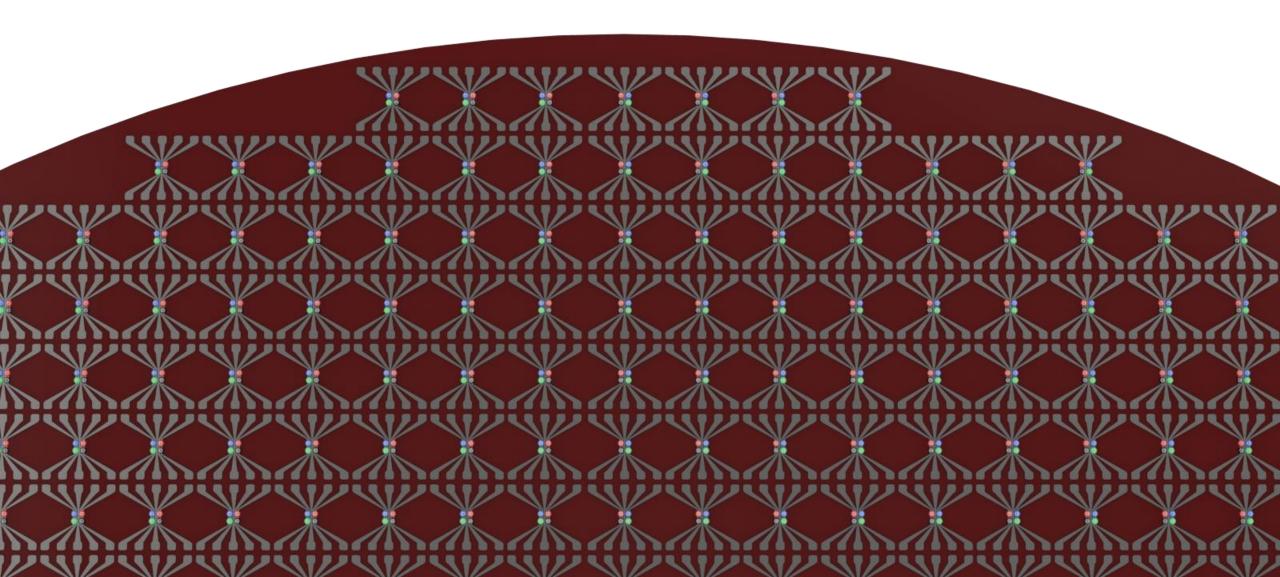
**Poor selectivity** Traditional Drop-casting

#### Good selectivity Electronic nose

Most popular solution: Use so-called electronic nose, an array composed of different metal oxides, could be operated at different temperatures, each showing a different response spectrum to gasses, in combination with pattern recognition software.



#### – How to manufacture?



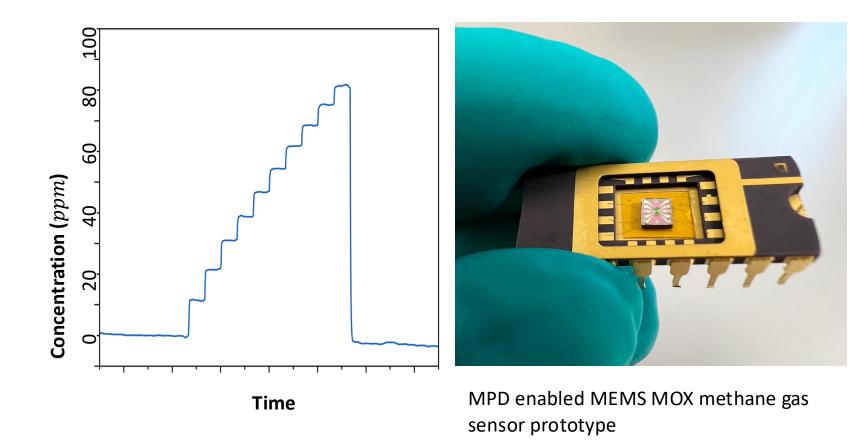
#### Drop-casting vs. MPD

Fabrication technology	Drop-casting	MPD
Min feature size (µm)	30	2.5
Aspect ratio	0.2	3
Time to print full wafer	Up to 10 hours	15 minutes
Accuracy	poor	High
Min. line spacing (µm)	30	5
Deposition scale	Locally	Wafer
Multiple materials	Yes	Yes

#### MPD methane sensor prototype

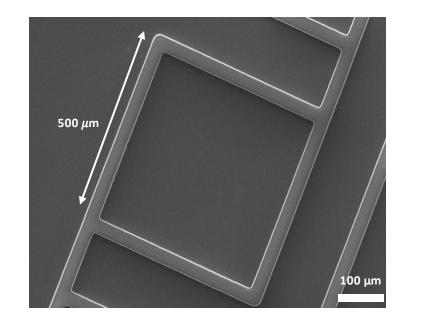
#### **Key Features**

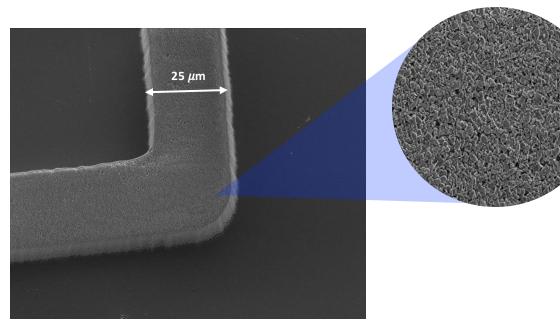
- Ultra-low consumption (20mW)
- Linear dependance on concentration
- Low-costs (Couple \$)
- Fast response ( $T_{90} < 30s$ )
- MEMS-based MOX
- Compact size (4mm<sup>2</sup>)



#### — Glass Frit Printing

MPD can be used to replace screen-printing to deposit lead-free glass frit for bonding with smaller and ultra-accurate bonding rims to improve device form factors. Typical bonding rim widths are between  $20 - 40 \mu$ m. Full 6 and 8-inch wafers can be deposited with glass frit.



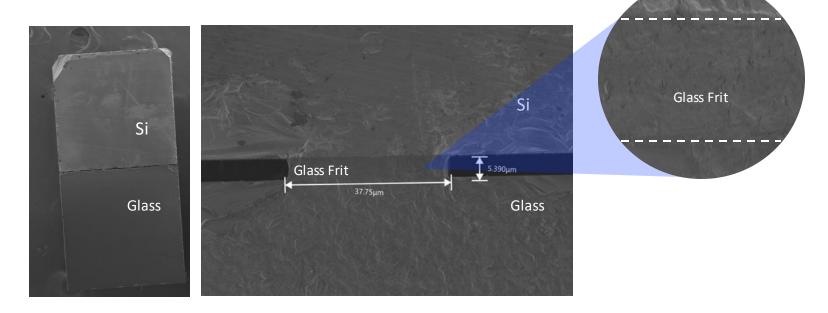


#### Glass Frit Bonding

MPD was used to accurately deposit glass frit bond lines on a Si wafer. The Si wafer was bonded to a Borosilicate bonding pair at 450°C with an EVG bonder. Subsequently, the wafers were diced.

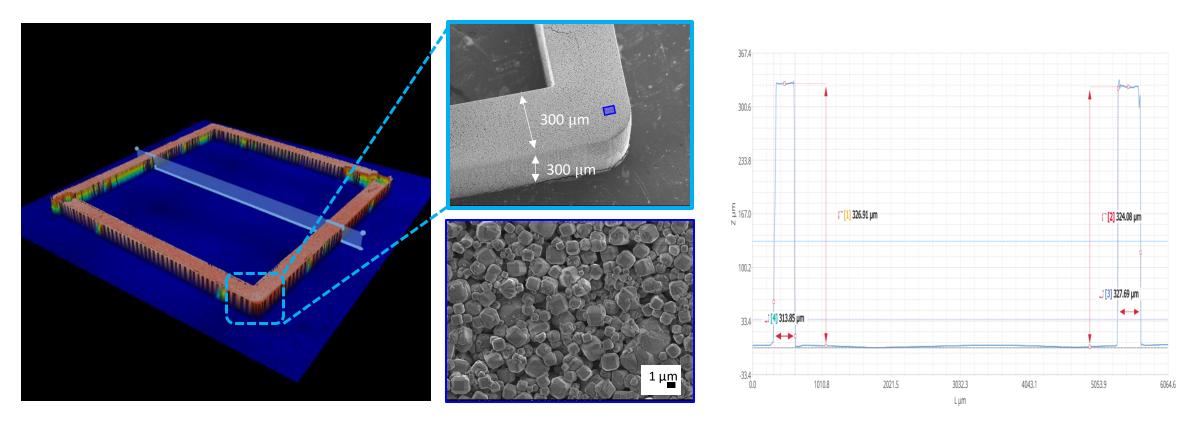
The bonding rim after bonding is  $\sim 38 \,\mu$ m wide and 5.3  $\mu$ m thick.





#### **Moisture Getter**

We have used our MPD technology to print moisture getters of approximately 300 x 300  $\mu$ m in dimensions with a square structure of 5 by 5 mm. MPD allows for more accurate deposition of getter material to decrease the device footprint while having the same getter capacity.



#### - From MIMIC to MPD

#### **MIMIC** micromolding steps Timeline (1996). Paper: Micromolding in Mesoline is the first and only company to Capillaries (MIMIC). Harvard commercialize and perfect MPD, an Place on a support to form micro-channels 2014 advanced version of the MIMIC process. University Place a drop of a fluid containing materials to be patterned R&D with nano-inks. 1996 2017 Caltech Fill channels by capillary action Complete surface reactions: Remove PDMS patterned material

#### Printing Services



Mesoline's manufacturing location is a 1.400 m<sup>2</sup> (15.000 ft<sup>2</sup>) facility in Rotterdam, NL. It includes a state-of-theart cleanroom, offering MPD production lines with quality assurance.

- Mesoline offers MPD printing services from design and prototyping to production on 100 mm (4-inch) up to 200 mm (8-inch) wafers
- Our production process is ISO-9001 certified
- Quality assurance systems include: 1) SEM, 2) EDX analysis,
  3) DLS, 4) optical profilometry, 5) confocal microscopy
- Total wafer capacity is 10.000 per year

### — Quality Assurance

#### Mesoline's MPD manufacturing process is ISO-9001 certified.

We maintain certification and rigorous compliance to ISO Quality Management System standards and apply them to every manufacturing process we undertake. Total quality from design through delivery is our objective in every customer engagement.

#### We provide quality control throughout the process:

- 1. Incoming wafers are inspected via optical profilometry;
- 2. Incoming powders are characterized through EDX analysis;
- 3. Our stamp manufacturing process includes various quality assurance steps to make sure the stamp is fabricated according to our standards before printing on actual wafer;
- 4. Inks are characterized through DLS (dynamic light scattering), SEM and EDX;
- 5. Outgoing, printed wafers are inspected via optical profilometry.



#### — Summary

- Mesoline has developed a new microfab method: microchannel particle deposition (MPD)
- MPD offers ultra-small & reproducible features while ensuring extensive parallelization and high scalability
- Superior microfabrication alternative in various market such as MEMS & sensors. More to discover!
- Mesoline provides MPD through manufacturing services





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## MESOLINE

